Coherently Controlled Nanoscale Molecular Deposition

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Quantum interference effects are shown to provide a means of controlling and enhancing the focusing of a collimated neutral molecular beam onto a surface. The nature of the aperiodic pattern formed can be altered by varying laser field characteristics and the system geometry.

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Light induced forces have been used to deflect, slow, accelerate, cool, and confine [1] neutral atoms. Similarly, and of particular interest here, atoms have been focused and deposited on surfaces on the nanometer scale [2,3]. In these cases, preliminary laser cooling followed by passage through an optical standing wave resulted in the formation of a periodic submicron atomic pattern on a surface. There are far fewer results for molecules, the most noteworthy being experiments [4] and theory [5] on focusing of molecules using intense laser fields. In this Letter we show that coherent control techniques [6] can be used to enhance and control the deposition of molecules on a surface, in *aperiodic,* nanometric scale patterns. The essence of the technique lies in the prepreparation of an initial controlled superposition of molecular eigenstates, followed by passage through an optical standing wave composed of two fields of related frequency. By varying the characteristics of the prepared superposition, or the characteristics of the optical standing wave, one can vary the induced dipole-electric field interaction, and hence alter the deposited pattern. The result demonstrates the utility of coherent control to manipulate the translational motion of molecules. Below we describe the general theory and provide computational results for the computationally convenient [7] molecule, N_2 .

The general configuration of the proposed control scenario is illustrated in Fig. 1. A beam of neutral molecules propagating along the *z* direction is prepared in a superposition of vibrotational states with a highly cooled transverse velocity distribution. Preparation is achieved either

by passing a precooled or precollimated beam through a preparatory electric field to create a superposition of vibrotational states in the ground electronic state, or by simultaneously preparing the superposition and cooling the transverse velocity by an extension of a recently proposed radiative association approach [8]. For simplicity we focus on a two-level superposition, i.e.,

$$
|\Psi(t)\rangle = c_1 |\phi_1\rangle e^{-iE_1t/\hbar} + c_2 |\phi_2\rangle e^{-iE_2t/\hbar}, \quad (1)
$$

where $|\phi_i\rangle$ are the eigenstates of the molecular Hamiltonian, of energy *Ei*.

The molecules then pass through a standing wave $E(x, t)$ composed of two electromagnetic fields which lie parallel to the surface and are polarized in the *z* direction. That is,

$$
\mathbf{E}(x,t) = [2E_1^{(0)} \cos(k_1x)e^{i\omega_1t} + \text{c.c.}]\hat{\mathbf{k}}
$$

$$
+ [2E_2^{(0)} \cos(k_2x + \theta_F)e^{i\omega_2t} + \text{c.c.}]\hat{\mathbf{k}}
$$

$$
\equiv [E(\omega_1) + \text{c.c.}]\hat{\mathbf{k}} + [E(\omega_2) + \text{c.c.}]\hat{\mathbf{k}}
$$
(2)

Here $\hat{\bf k}$ denotes a unit vector in the *z* direction, c.c. denotes the complex conjugate of the terms preceding it, θ_F is the relative phase of the two standing waves (SW), $E_j^{(0)}$, k_i , and ω_i are the maximum amplitude, wave vector, and frequency of the *j*th standing wave, of wavelength λ_i .

The potential energy of interaction $V(x)$ of the molecule with the field $\mathbf{E}(x, t)$ is $V(x) = -\mu^{\text{ind}} \cdot \mathbf{E}(x, t)$, where μ^{ind} is the induced dipole moment. Within first order perturbation theory, the induced dipole of the superposition state in the presence of the two fields, chosen so that E_1 + $\hbar\omega_1 = E_2 + \hbar\omega_2$, is given by [7]

$$
\boldsymbol{\mu}^{\text{ind}} = \chi^{\text{in}}(\omega_1)E(\omega_1) + \chi^{\text{ni}}(\omega_1)E(\omega_1) + \chi^{\text{in}}(\omega_2)E(\omega_2) + \chi^{\text{ni}}(\omega_2)E(\omega_2) + \chi^{\text{in}}(\omega_{21} + \omega_1)E(\omega_{21} + \omega_1) + \chi^{\text{in}}(\omega_{21} - \omega_2)E(\omega_{21} - \omega_2) + \text{c.c.},
$$
\n(3)

where $E(\omega_{21} + \omega_1) = 2E_1^{(0)} \cos(k_1x)e^{i(\omega_{21} + \omega_1)t}$ and $E(\omega_{21} - \omega_2) = 2E_2^{(0)} \cos(k_2x + \theta_F)e^{i(\omega_{21} - \omega_2)t}$. The χ are the following contributions to the *zz* component of the polarizability:

$$
\chi^{\text{in}}(\omega_{1}) = \frac{1}{\hbar} \sum_{j} c_{1} c_{2}^{*} \left[\frac{\mu_{j1}^{z} \mu_{2j}^{z}}{\omega_{j1} + \omega_{2}} + \frac{\mu_{j2}^{z} \mu_{1j}^{z}}{\omega_{j2} - \omega_{2}} \right] \frac{E_{2}^{(0)}}{E_{1}^{(0)}},
$$
\n
$$
\chi^{\text{in}}(\omega_{2}) = \frac{1}{\hbar} \sum_{j} c_{2} c_{1}^{*} \left[\frac{\mu_{j2}^{z} \mu_{1j}^{z}}{\omega_{j2} + \omega_{1}} + \frac{\mu_{j1}^{z} \mu_{2j}^{z}}{\omega_{j1} - \omega_{1}} \right] \frac{E_{1}^{(0)}}{E_{2}^{(0)}},
$$
\n
$$
\chi^{\text{ni}}(\omega_{1}) = \frac{1}{\hbar} \sum_{j} \sum_{i=1,2} |c_{i}|^{2} \mu_{ji}^{z} \mu_{ij}^{z} \left[\frac{1}{\omega_{ji} + \omega_{1}} + \frac{1}{\omega_{ji} - \omega_{1}} \right],
$$

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FIG. 1. Schematic of the proposed control scenario.

$$
\chi^{\mathrm{ni}}(\omega_2) = \frac{1}{\hbar} \sum_j \sum_{i=1,2} |c_i|^2 \mu_{ji}^z \mu_{ij}^z \left[\frac{1}{\omega_{ji} + \omega_2} + \frac{1}{\omega_{ji} - \omega_2} \right],
$$

$$
\chi^{\text{in}}(\omega_{21} + \omega_1) = \frac{1}{\hbar} \sum_{j} \left[c_1 c_2^* \frac{\mu_{j1}^2 \mu_{2j}^2}{\omega_{j1} + \omega_1} + c_1^* c_2 \frac{\mu_{j2}^2 \mu_{1j}^2}{\omega_{j2} - \omega_1} \right],
$$

$$
\chi^{\text{in}}(\omega_{21} - \omega_2) = \frac{1}{\hbar} \sum_{j} \left[c_1 c_2^* \frac{\mu_{j1}^2 \mu_{2j}^2}{\omega_{j1} - \omega_2} + c_1^* c_2 \frac{\mu_{j2}^2 \mu_{1j}^2}{\omega_{j2} + \omega_2} \right],
$$

where $\omega_{ij} = (E_j - E_i)/\hbar$ and $\mu_{ij}^z = \langle \phi_i | \mu \cdot \hat{\mathbf{k}} | \phi_j \rangle$. Here the superscripts "in" and "ni" refer to the interference and noninterference contributions to χ , the interference terms being the direct consequence of the established coherence between $|\phi_1\rangle$ and $|\phi_2\rangle$ [Eq. (1)]. The summation in the above equations runs over all the vibrational and rotational states. For example, in the particular case of *N*2, examined below, vibrotational states of six excited electronic states $(b^{11}\sum_{u}^{1}$, $c^{11}\sum_{u}^{1}$, $e^{t1}\sum_{u}^{1}$, $b^{1}\prod_{u}$, $c^{1}\prod_{u}$, and $o^1\Pi_u$) are included.

The final expression for the potential within the rotating wave approximation is then given by

$$
V(x) = -\mu^{\text{ind}} \cdot \mathbf{E}(x, t) = V^{\text{ni}}(x) + V^{\text{in}}(x), \tag{4}
$$

where

$$
-V^{\text{ni}}(x) = 2[4E_1^{(0)^2}\cos^2(k_1x)\chi^{\text{ni}}(\omega_1) + 4E_2^{(0)^2}\cos^2(k_2x + \theta_F)\chi^{\text{ni}}(\omega_2) + 4E_1^{(0)}E_2^{(0)}\cos(k_1x)\cos(k_2x + \theta_F)[\chi^{\text{ni}}(\omega_1) + \chi^{\text{ni}}(\omega_2)]\cos(\omega_1 - \omega_2)t
$$
(5)

and

$$
-V^{\text{in}}(x) = 2\{4E_1^{(0)^2}\cos(k_1x)\cos(k_2x + \theta_F)\chi_r^{\text{in}}(\omega_1) + 4E_2^{(0)^2}\cos(k_1x)\cos(k_2x + \theta_F)\chi_r^{\text{in}}(\omega_2) + 4E_1^{(0)}E_2^{(0)}\cos^2(k_2x + \theta_F)[\chi_r^{\text{in}}(\omega_1)\cos(\omega_1 - \omega_2)t - \chi_l^{\text{in}}(\omega_1)\sin(\omega_1 - \omega_2)t] + 4E_1^{(0)}E_2^{(0)}\cos^2(k_1x)[\chi_r^{\text{in}}(\omega_2)\cos(\omega_2 - \omega_1)t - \chi_l^{\text{in}}(\omega_2)\sin(\omega_2 - \omega_1)t]\}.
$$
(6)

Here χ_r^{in} and χ_l^{in} denote the real and imaginary parts of the *zz* component of χ^{in} . Computations show that the time dependent contributions to Eqs. (5) and (6) average out and may be neglected. The resultant time independent "optical potential" displays a series of maxima and minima along *x*, with each minima serving to focus the molecules, and each maxima serving to defocus them. The structure of $V(x)$ and hence its effect on the molecule's dynamics depends upon the *control parameters* $E_1^{(0)}$, $E_2^{(0)}$, c_1 , c_2 , θ_F and the quantum numbers ν_i , *J*, *M*.

The extent to which control is possible is evident from the computational results shown below on $N₂$ (a molecule chosen solely for computational convenience). Here $|\phi_i\rangle \equiv |\nu_i, J_i, M_i\rangle$, where ν_i and J_i are the vibrational and rotational quantum numbers, respectively, and M_i is the projection of *Ji* along the *z* direction. Selection rules imply [7] that χ^{in} is zero unless $|\phi_1\rangle$ and $|\phi_2\rangle$ are of the same parity. To this end we employ a two photon preparatory step so that $J_2 = J_1 + 2$, $M_1 = M_2$.

As an example, we compute classical trajectories for the deposition of N_2 on a surface, reported as the number of trajectories $N(x)$ incident on the surface in a Δx interval of 1.403 nm. Our initial studies examined deposition using a nozzle width of 20 μ m and a similar sample size. Results for the chosen parameters ($\lambda_1 = 0.628 \mu \text{m}, \lambda_2 =$ 0.736 μ m) showed an almost periodic repeating of patterns of $3-4 \mu m$ width. Hence we here focus down to this subregion, with computations simplified by reducing the nozzle diameter and sample size to $4\lambda_2 = 3 \mu$ m. The initial velocity along z is taken as 600 m/sec, and the transverse velocity is assumed to be zero. Additional computations show that corrections to include a transverse velocity distribution can be incorporated in accord with Ref. [3]. That is, for a Gaussian transverse velocity distribution peaked about zero and of width σ , we find that tribution peaked about zero and of width σ , we find that the deposited peaks are broadened by $\approx\sqrt{2} t_{\text{int}} \sigma$ while the ratios of peak height to background level are decreased by $\approx 1/\sqrt{\pi}t_{int}\sigma$, where t_{int} is the interaction time between the molecule and the field.

Classical trajectories are computed for the motion of the N_2 center of mass in the presence of $V(x)$, which is encountered for the time period $t = 0$ to $t = t_{int}$ [9]. We adopt an aspect of the ballistic aggregation model [10] and assume that all molecules that strike the surface stick without diffusing. Note also that although trajectories are computed for N_2 as a point particle, the $V(x)$ encountered by N_2 depends on the molecule's J, M through its effect on χ [11].

Consider first simple cases involving only a single superposition of states. Figure 2 shows the results in the presence and absence of interference contributions for a superposition composed of $|0, 0, 0\rangle$ and $|0, 2, 0\rangle$. Specifically, 2(a) and 2(b) show the pattern of deposition, and the associated optical potential, for dynamics in the presence of $V(x) = V^{\text{in}}(x) + V^{\text{ni}}(x)$. For comparison we show, in $2(c)$ and $2(d)$, the corresponding results assuming that there is no coherence between $|\phi_1\rangle$ and $|\phi_2\rangle$, i.e., neglecting $V^{\text{in}}(x)$. In the absence of molecular coherence the optical potential is seen to be [Fig. 2(d)] periodic, resulting in a series of short periodic deposition peaks [Fig. 2(c)]. By contrast, the inclusion of interference contributions [Figs. 2(a) and $2(b)$] result in significant enhancement and narrowing of peaks [5 times narrower (FWHM of less than 4 nm) and 4 times more intense], as well as the appearance of an aperiodic potential and associated aperiodic deposition pattern. Quantitative consideration of the peaks shows that they are in general in accord

FIG. 2. Molecular deposition and associated optical potential FIG. 2. Molecular deposition and associated optical potential
for the initial superposition $\sqrt{0.8}$ $|0, 0, 0\rangle + \sqrt{0.2}$ $|0, 2, 0\rangle$ due to $V(x) = V^{\text{in}}(x) + V^{\text{ni}}(x)$ [(a) and (b)], and due to $V(x)^{\text{ni}}$ only [(c) and (d)]. Here $\frac{E_2^0}{E_1^0} = 1.0 \times 10^4$, $E_1^0 = 1.0 \times$ 10^2 V/cm, $\lambda_1 = 0.628$ μ m, $\lambda_2 = 0.736$ μ m, $\theta_F = -2.65$ radian, and $t_{\text{int}} = 0.625 \mu \text{sec}$. Results are from a sample of 20 000 trajectories.

with the theory outlined in Ref. [3]. That is, a sharp peak forms in the region of the potential minima when $t_{\text{int}} \sim (2n + 1)T/4$, where *T* is the optical period for a particular potential well. In the presence of $V^{\text{in}}(x)$ not all potential wells have the same period. Hence, deposition is not periodic and is dependent on the interrelationship between t_{int} and the period T of each different well.

The optical potential $V(x)$ and hence the nature of the deposition pattern is seen to depend analytically [see Eqs. (4)–(6)] on the contributing $|\phi_i\rangle$, the coefficients c_i , the phase θ_F , the fields $E_i^{(0)}$, and the time of interaction *t*int between the field and the molecule. Of these, numerical studies on the relative phase θ of the c_i , an important parameter in coherent control studies of photodissociation and bimolecular scattering [6], show that it does not significantly affect the deposition pattern. Consideration of Eq. (4) shows that this is because changes in θ do not affect the positions of the extrema of $V(x)$, and result only in small changes in the depth of the minima. By contrast, changes in the other parameters can strongly affect the structure of the deposited pattern. For example, Figs. 3(a) and 3(b) show significant differences in both the position and the intensity of the peaks as a function of θ_F . By contrast, consideration of the analogous plot where only V^{ni} is considered (not shown) shows no variation in peak intensity as a function of θ_F . Similarly, Figs. 3(c) and 3(d) show the strong dependence of the deposition upon the magnitude of the coefficients of the created superposition. Clearly, varying these parameters affords a wide range of control over the deposited pattern.

FIG. 3. (a),(b) Molecular deposition associated with $\sqrt{(0.9)}$ loop. $\sqrt{(0.8)}$ |000) + $\sqrt{(0.2)}$ |1, 2, 0) for varying θ_F , i.e., (a) $\theta_F = 0$ and (b) $\theta_F = 2.0$. (c),(d) Sample variation of deposition with and (b) $\theta_F = 2.0$. (c),(d) Sample variation of deposition with
changes in $|c_1|, |c_2|$: (c) $\sqrt{0.99} |0, 0, 0 \rangle + \sqrt{(0.01)} |0, 2, 0 \rangle$; changes in $|c_1|$, $|c_2|$: (c) $\sqrt{0.99} |0, 0, 0\rangle + \sqrt{0.01} |0, 2, 0\rangle$;
(d) $\sqrt{0.4} |0, 0, 0\rangle + \sqrt{0.6} |0, 2, 0\rangle$. Other parameters are as in Fig. 2.

FIG. 4. Molecular deposition with (a) and without (b) molecular coherence for the mixed state at temperature $T = 298$ K, as described in text. Remaining parameters are as in Fig. 2 except that results are obtained from 1.23×10^6 trajectories and $t_{\text{int}} = 0.467 \mu \text{m}$.

Finally, consider control over a beam of molecules with a thermal distribution of molecular level populations. That is, consider the case where the initial collimated molecular beam is in a mixture of states $\sum_{i,j} w_{i,j} |0, J_i, M_j\rangle \langle 0, J_i, M_j|$, with the weights w_{ij} given by a Boltzmann distribution at $T = 298$ K. In this instance 20 *J* states are populated. By passing this mixture through a square pulse of field strength 3.25×10^9 V/m and frequency width 75.4 cm^{-1} , we excite all 19 states to pairwise superpositions of *J* states. That is, we produce the $\sum_{i,j} w_{i,j} [c_{i,j} | 0, J_i, M_j \rangle \langle 0, J_i, M_j | + d_{i,j} | 0, J_i +$ $\langle 2, M_j \rangle \langle 0, J_i + 2, M_j |]$ where $|d_{i,j}|^2 = 1 - |c_{i,j}|^2$. At the chosen field strength, *dij* can be computed in perturbation theory [7], the final result being that the mixture of superpositions has the coefficient $c_{0,0}$ associated with superpositions has the coefficient $c_{0,0}$ associated with the state $|0, 0, 0\rangle$ on the order of $\sqrt{0.8}$. This mixed state is then passed through the two stationary fields and the deposition pattern computed. Results for one such case are shown in Fig. 4 where results including the coherence contributions V^{in} are shown in $4(a)$ and contrasted with the results where only the noninterference terms are included [Fig. 4(b)]. The results are quite similar to those of the single superposition shown in Figs. 2 and 3 above. That is, including the interference, in addition to eliminating the periodicity, results in more intense, sharper lines. Examination of $V(x)$ as a function of J, M shows that the lack of broadening of the peaks with the mixing of *J*, *M* levels is a result of the fact that changing *J*, *M* alters only the depth of the $V(x)$ minima, and not their location.

In summary, we have shown that introducing a coherence between molecular energy levels, in conjunction with two frequency related electromagnetic fields, introduces a set of parameters that allow for control over the nanoscale

molecular deposition pattern. Further work is needed to consider the possibility of depositing any arbitrary pattern, to examine the focusing of larger molecules (which have inherently larger polarizabilities and should be more easily focused), and to consider the effects of more intense cw fields. Work to this effect is in progress.

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